



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

OHTAKE, Fumio et al.

Group Art Unit: **2814**

Serial No.: **09/749,590**

Examiner: **MAI, Anh D.**

Filed: **December 28, 2000**

P.T.O. Confirmation No.: **4831**

For: **SEMICONDUCTOR DEVICE HAVING GATE ELECTRODES WITH POLYMETAL
STRUCTURE OF POLYCRYSTALLINE SILICON FILMS AND METAL FILMS (as
amended)**

AMENDMENT UNDER 37 CFR §1.111

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

September 8, 2003

Sir:

In response to the Office Action dated May 7, 2003, please amend the above-identified application
as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this
paper.

Remarks/Arguments begin on page 8 of this paper.

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